#2/Pre-Amost A 4-18-02/10

PATENT Customer No. 22,852 Attorney Docket No. 7447.0021-01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Jeng Ping LU et al.

Group Art Unit: Unknown

Rule 53(b) Divisional of Prior Application: Serial No. 09/419,293, filed 10/15/99

Examiner: Unknown

Serial No.: Not Yet Assigned

For:

DUAL DIELECTRIC STRUCTURE

FOR SUPPRESSING LATERAL LEAKAGE CURRENT IN HIGH FILL FACTOR ARRAYS

Commissioner for Patents and Trademarks Washington, DC 20231

Sir:

PRELIMINARY AMENDMENT

Prior to the examination of the above application, please amend this application as follows:

IN THE CLAIMS:

Please cancel claims 1-6, without prejudice or disclaimer of the subject matter, and add new claims 11-15, as follows:

11. (New) A high fill factor image array formed by:

providing a plurality of source-dfain metal contacts;

depositing a first passivation layer;

depositing a second passivation layer over the first passivation layer that suppresses lateral leakage current;

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